	Application No.	Applicant(s)
Notice of Allowability	09/890,364	DUINEVELD ET AL.
	Examiner	Art Unit
	Sharlene Leurig	2879
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to the Request for Continued Examination of November 12, 2004.		
2. The allowed claim(s) is/are <u>1-10</u> .		
3. The drawings filed on 30 July 2001 are accepted by the Examiner.		
4.		
 Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 102904,111204 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material 	6. ☑ Interview Summary Paper No./Mail Dat 8), 7. ☐ Examiner's Amendr	tè <u>0405</u> .

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DETAILED ACTION

Information Disclosure Statement

1. The Information Disclosure Statement mailed October 29, 2004 and faxed November 12, 2004 cites international application WO 00/48339. The cited reference has been considered, but is not related to the art of the claimed invention. Along with the IDS, applicant sent JP 2000-353594, which is related to WO 99/48339, which is directed to deposition of an electroluminescent layer. The examiner contacted the applicant's representative on April 7, 2005 to inquire if the applicant might have intended to cite international application WO 99/48339, which is entitled "Substrate for Patterning Thin Film and Surface Treatment Thereof. The applicant's representative, as of the present date, has not contacted the examiner to clarify the issue at hand. In order to conduct a thorough search, the examiner has considered both international application WO 99/48339 and the US application 10/686,634, published as US 2004/0201048 A1, which is a continuation of US application 09/423,969, and national stage of the international application WO 99/48339.

Allowable Subject Matter

2. Claims 1-10 are allowed.

The following is an examiner's statement of reasons for allowance:

Seki et al. (US 2004/0201048 A1) teaches an OEL device having an organic electroluminescent layer disposed between a relief pattern, the organic electroluminescent layer having a certain thickness (paragraph 0209).

The prior art of record fails to teach or suggest the combination of limitations as set forth in claims 1 and 5, and specifically comprising an organic electroluminescent device or a method of making an organic electroluminescent device having an organic electroluminescent layer having less than perfectly uniform thickness, and specifically where at least 55% of the layer, but less than 100% of the layer, has a thickness within 20% of the minimum thickness or within 20% maximum thickness of the layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sharlene Leurig whose telephone number is (571) 272-2455. The examiner can normally be reached on Monday through Friday, 8:30am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimesh Patel can be reached on (571) 272-2457. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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NIMESHKUMAR D. PATEL SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800